

## Optical and Thermal Characterizations of Metal-Insulating Phase Transition Titanium(III) Oxide

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Titanium(III) Oxide ( $\text{Ti}_2\text{O}_3$ ) is a phase transition oxide with a metal-to-insulating temperature (MIT) near 200°C. Optical and thermal measurements of  $\text{Ti}_2\text{O}_3$  can benefit the design and implementation of tunable radiative emission coatings, where the compositional  $x$  in  $\text{TiO}_{2-x}$  is sought to change the MIT. We have grown  $\text{TiO}_{2-x}$  film by well-controlled molecular beam epitaxy (MBE). The MBE process provided precision control of  $x$ , while providing *in situ* Auger stoichiometry measurements. The objective of our thin film synthesis and spectrometry is to provide a broadband infrared spectrum of temperature-dependent dielectric functions of  $\text{Ti}_2\text{O}_3$ . A 700 Å  $\text{TiO}_{2-x}$  film has been grown by MBE at room temperature, with a slow controlled deposition rate being 0.32 Å per minute. The presence of a phase transition is apparent in the color with the respective change in the amount of oxygen in the film, with its blue shade indicating  $x$  near 0.25 ( $\text{Ti}_2\text{O}_{3.50}$ ). This corresponds to the  $\text{Ti}_2\text{O}_3$  corundum phase. We noticed depositions in  $10^{-7}$  Torr background pressure of  $\text{O}_2$  caused the film color to be rusty brown. Annealing in UHV created the oxygen deficiency / vacancy in the film with reappearance of blue shade and Auger estimated stoichiometry of  $\text{Ti}_2\text{O}_{3.50}$ . Subsequent depositions necessitate UHV anneal to achieve the stoichiometry closer to  $\text{Ti}_2\text{O}_3$  for optically thick films  $>1000$  Å. The optical measurements were carried out in UV/vis ellipsometry to obtain VASE models for precise thin film thickness. An FTIR with heater-controlled backside in variable reflectance configuration provided spectra between room temperature and 200°C, normalized to a heated reference. The ongoing task of thermal and spectral characterizations can enable development of plasmonic emitters, with aptly corresponding blackbody emissions in the mid-infrared.